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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/663,077	09/16/2003	Hiroshi Funada	CU-6013	2051
26530 7590 02/14/2008 LADAS & PARRY LLP 224 SOUTH MICHIGAN AVENUE SUITE 1600 CHICAGO, IL 60604			EXAMINER ANGEBRANDT, MARTIN J	
			ART UNIT 1795	PAPER NUMBER
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary

Application No.

10/663,077

Applicant(s)

FUNADA ET AL.

Examiner

Martin J. Angebrandt

Art Unit

1795

Period for Reply -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 9/25/07.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1, 2, 5 and 8-15 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1, 2, 5 and 8-15 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-946)
- 3) ☐ Information Disclosure Statement(s) (PTO/CDC)
- 4) ☐ Interview Summary (PTO-413)
- 5) ☐ Notice of Informal Patent Application
- 6) ☐ Other: _____
- Paper No(s)/Mail Date _____

Art Unit: 1795

1. The response of the applicant has been read and made of record. Responses to the arguments of the applicant are presented after the first rejection to which they are directed. The amended figures and text are accepted for entry into the specification. Rejections from the previous office action not repeated below are withdrawn based upon the amendments and arguments of the applicant. If the complete reference is not sent, then do not cite it as such, cite abstracts alone under other documents.

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 102(b) as being fully anticipated by Shvartsman '689.

Shvartsman '689 teaches with respect to figure 1, a process where a photosensitive layer (14) is laminated on a substrate (10) and embossed with a holographic embossing master (20)

and photocured using UV radiation while in contact with the embossing master (20) and then peeled from the embossing master. Figure 3 shows the embossing contact and the UV curing occurring in the same station. This is illustrated in figure 2a-f. It can be seen clearly in the illustration of figure 2d, that the protrusions (pointing downward) are uniform in width, while 3rd, 7th, 9th, 12th, 14th and 18th grooves are wider than the adjoining protrusion, while the other grooves are have widths similar to that of the protrusions. (2/42-52, 10/58-11/41)

The holographic master of Shvartsman '689 is the duplication plate having the protruding/peak shape narrower than at least one of the adjoining groove/valleys as discussed above. The application discloses that UV is ionizing radiation in the prepub of the instant specification in figure 2 and [0091]. As the groove widths vary requirement (a) is met, as it is a relief hologram s, requirement (c) is met and as there are a plurality of peak/protrusion and valley/groove shapes/features with the peaks/protrusions being separated from each other by grooves, requirement (b) is met.

5. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over by Edwards WO 99/52105, in view of Nebashi et al. '870 and Takahashi et al. JP 02-010536.

Edwards WO 99/52105 describes master disks which can be used in disk molding processes to form replica disks having wide flat lands and deep narrow grooves. (10/25-11/5). In figures 16-18, the pitch is 0.375 microns (375 nm) and the width at the flat bottom of the groove is 146, 185 or 205 nm. Figure 19 shows the use of intermediate masters. The use of molding to form the optical disk substrates is disclosed. (17/1-10 and 18/5-15). Photopolymers for forming replication layer (replica disks) are disclosed. (page 20) As the width of the flat part of the recess is nearly equal to or greater than $\frac{1}{2}$ the pitch and the protrusions are pointed (ie no width),

the cross-sectional area of the protrusions above the midline is held to be less than the cross-sectional area of the recesses below the mid-depth line of the recesses.

Nebashi et al. '870 teaches the formation of a stamping master, where the grooves having a width of 0.35 microns are formed in the stamping master, which is then coated with a light curing resin, a backing plate applied and UV light used to cure the resin to form an optical recording medium substrate of an olefin polymer with the grooves being formed in a UV cured resin, which is then coated to form the recording medium. (10/23-45)

Takahashi et al. JP 02-010536 (translation attached) teaches molding optical recording media substrates and establishes the equivalence of injection, compression and 2P (polymerization) molding processes (translation on page marked 16, last full paragraph).

It would have been obvious to use the master of Edwards WO 99/52105 directly to form a replica disk using a 2P process such as that described by Nebashi et al. '870, where a radiation curable resin is used to form the replica optical disk substrate based upon the direction to molding and the use of photopolymerizable materials to form replicas by Edwards WO 99/52105 and the disclosure of equivalence in the various molding techniques by Takahashi et al. JP 02-010536.

As the corrugations are circular, their direction is considered to change continuously, thereby meeting the limitations of claim 6.

The applicant argues that the references applied are directed to optical recording media and that therefore they are not embraced by the diffractive claims language. **The examiner notes that the grooves are formed at regular intervals (pitch) and that they diffract light. The applicant may look at a CD to verify this and note the diffraction of the light into the**

different colors. The optically diffraction layer is the curable resin and the language of the claims makes it clear that this is embossed/molded by the duplication plate material. The composition of the duplication plate material is not recited in the claim, so the embossing means described in either of Edwards WO 99/52105 or Nebashi et al. '870 meet claims 1 and 5. The replica discs 1, and 3 have the same polarity as the photoresist master disc and therefore have a greater spacing between the protrusion features than the width of the protruding features. This is also illustrated in figures 2a-3B, where the stamper is coated with resin 22 which is hardened and released to form layer 23 and then coated with a resin (31) which is hardened and used as the final disc substrate where the protrusions are narrower than the grooves separating them. This also shows the use of cured materials as the material performing the embossing/molding. The rejection stands.

The optical recording stamping master of Edwards WO 99/52105 is the duplication plate having the protruding/peak shape narrower than at least one of the adjoining groove/valleys as discussed above. The application discloses that UV is ionizing radiation in the prepub of the instant specification in figure 2 and [0091], which is the radiation used in the replication process of Nebashi et al. '870. As the groove widths vary requirement (a) is met, as it is inherently a relief hologram (concentric in the same manner as a Fresnel lens hologram), requirement (c) is met and as there are a plurality of peak/protrusion and valley/groove shapes/features with the peaks/protrusions being separated from each other by grooves, requirement (b) is met. The intermediate product of the embossed substrate and the process for its formation as discussed above meet the claims. The examiner is not stating that the final optical recording media necessarily meets the claims as it may be coated with a recording layer, but the language of the

claims fails to exclude concentric diffractive patterns, such as those found in optical recording media substrates. The claims describe the portions of the structure of the holographic features/topography, but not the appearance of the final articles. The applicant argues that a visually bright structure is formed, but fails to appreciate that this is not the case until the reflective layer (27) is applied. The applicant does not seem to appreciate that the groove structure is a grating. The examiner notes that Martens '850 establishes the equivalence of diffraction gratings and video disks. The curing can be either during or after the embossing and meet the claims.

6. Claims 1,2,5 and 8-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over by Edwards WO 99/52105, in view of Nebashi et al. '870 and Takahashi et al. JP 02-010536, further in view of Parker et al. '825.

Parker et al. '825 teach that the formation of holograms using an embossing shim applied to the outer surface of a roller. (1/24-60,2/11-55). The use of a shim wrapped around a cylinder and to emboss/mold optical recording media substrates (1/61-2/10).

In addition to the basis provided above, the examiner holds that it would have been obvious to one skilled in the art to modify the process of Edwards WO 99/52105, in view of Nebashi et al. '870 and Takahashi et al. JP 02-010536 by using an embossing shim wrapped about a roller as this is old and well known in the art as evidenced by Parker et al. '825.

7. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689, in view of Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063.

Ueda et al. JP 2000-063459 teach the UV curing after the embossing step has been completed [0036, 045,0048]. (machine translation attached)

Sakguchi JP 05-046063 teaches the UV curing after the embossing step has been completed [0024]. (machine translation attached).

In addition to the basis provided above, the examiner holds that it would have been obvious to one skilled in the art to modify the process of Shvartsman '689 by performing the curing after separation from the embossing master as taught by either of Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063 with a reasonable expectation of forming a useful holographic replica as these are alternative shown in the art to be equivalent.

8. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689 alone or combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063), in view of Parker et al. '825.

In addition to the basis provided above, the examiner holds that it would have been obvious to one skilled in the art to modify the process of Shvartsman '689 alone or combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063) by using an embossing shim wrapped about a roller as this is old and well known in the art as a means for embossing longer/larger structures as evidenced by Parker et al. '825.

9. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Webster et al. '385, in view of Martens '850.

Webster et al. '385 teaches the formation of diffraction gratings where the relief pattern is embossed into a plastic sheet, metalized, and then overcoated with an adhesive layer and a protective layer. The duty cycle is chosen based upon the optimum according to Maxwell's equations according to the desired color saturation (7/45-53 and 8/47-9/7). The grating pitch determines the color (10/19 and the formation of two areas having different gratings is disclosed

with respect to figure 4. The formation of different grating depths is also shown in the figures(see 4a).

Martens '850 teaches methods for replicating diffraction gratings, video disks and the like using photocurable compositions. (1/5-14). These processes are described as having better fidelity of the original image than hot stamping or other embossing processes. (1/15-26). Various masters are disclosed (39/13-40/5). In example 21, the process is described with respect to figure 9, as the photocurable resins is pumped onto the master dies bearing the relief pattern, the back is provided with a polyester backing/support, the UV mercury arc lamps are used to cure the resin, resulting the patterned laminate bearing a (diffractive) Fresnel lens (55/11-50). Figures 10B shows the case where either large or small protrusions relative to the grooves/recesses are formed (4/8-38).

It would have been obvious to one skilled in the art to modify the teachings of Webster et al. '385 to use duty cycles of more than 50% in the optimization of the color saturation according to Maxwell's equations based upon the direction to do so and to use other processes, such as that of Martens '850 using photocurable resins, in place of the stamping methods to increase the fidelity as taught by Martens '850 and further in view of the known use of gratings with the crosssection shown in figure 10B in Martens '850.

In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck & Co.*, 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986). The optically diffraction layer is the curable resin and the language of the claims makes it clear that this is embossed/molded by

Art Unit: 1795

the duplication plate material. The composition of the duplication plate material is not recited in the claim, so the embossing means described in either of Webster et al. '385 or Martens '850 meet the claim limitations. The use of the UV curable resins as the replication medium is clearly taught by Martens '850, who also along with Webster et al. '385 teach media which have a duty cycle such that the protrusions are smaller in width than the grooves separating them. The rejection stands.

10. Claims 1,2,5 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Webster et al. '385, in view of Martens '850 combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063).

In addition to the basis provided above, the examiner holds that it would have been obvious to one skilled in the art to modify the processes rendered obvious by the combination of Webster et al. '385 and Martens '850 by performing the curing after separation from the embossing master as taught by either of Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063 with a reasonable expectation of forming a useful holographic replica as these are alternative shown in the art to be equivalent.

11. Claims 1,2,5 and 8-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Webster et al. '385, in view of Martens '850 alone or combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063) further in view of Parker et al. '825.

In addition to the basis provided above, the examiner holds that it would have been obvious to one skilled in the art to modify the process of Webster et al. '385, in view of Martens '850 or further combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063) by using

an embossing shim wrapped about a roller as this is old and well known in the art as evidenced by Parker et al. '825

12. Claims 1,2,5 and 8-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Webster et al. '385 combined with Martens '850 and Parker et al. '825 alone, or further combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063), in view of Yoshitake et al. '078 or Sakuri et al. '479.

Yoshitake et al. '078 teaches the formation of decorative gratings where the diffraction angles, and directions are distributed randomly in a predetermined range to make the patterns noticeable. (9/9/60-65). The formation of various patterns is disclosed. with respect to the figures.

Sakuri et al. '479 teaches features with different heights (figure 2).

In addition to the basis set forth above, it would have been obvious to one skilled in the art to modify the process of Webster et al. '385 as modified by Martens '850 and Parker et al. '825 or as modified by Martens '850, Parker et al. '825 and (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063) by using it to form decorative holographic/grating patterns with randomly varied orientations as taught by Yoshitake et al. '078 and different heights as taught by Sakuri et al. '479 with a reasonable expectation of forming useful decorative holograms.

13. Claims 1,2,5 and 8-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shvartsman '689 and Parker et al. '825 alone, or combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063), further in view of Yoshitake et al. '078 or Sakuri et al. '479.

In addition to the basis set forth above, it would have been obvious to one skilled in the art to modify the process of Shvartsman '689 as modified by Parker et al. '825 or as modified by

Art Unit: 1795

Parker et al. '825 combined with (Ueda et al. JP 2000-063459 or Sakguchi JP 05-046063), by using it to form decorative holographic/grating patterns with randomly varied orientations as taught by Yoshitake et al. '078 and different heights as taught by Sakuri et al. '479 with a reasonable expectation of forming useful decorative holograms.

14. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Martin J. Angebranndt whose telephone number is 571-272-1378. The examiner can normally be reached on Monday-Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Martin J Angebranndt/
Primary Examiner, Art Unit 1795

Martin J Angebranndt
Primary Examiner
Art Unit 1795

